## Mo-SiN<sub>x</sub> granular metal high-pass filters

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Granular metals (GMs) comprise a 3D network of metal nanoparticles embedded in a dielectric matrix. Over the past ~50 years, GM investigations have spanned fundamental physics to unique applications, including Au-SiO<sub>2</sub> GMs used as insulating contacts in vidicons, video cameras used in NASA's Apollo and Voyager missions [1]. As a controlled platform for electron transport studies, GMs exhibit tunneling transport (*e.g.* variable-range hopping, Poole-Frenkel conduction in Ni-SiO<sub>2</sub> GMs) and frequency-dependent conductivity  $\sigma(\omega)$  in Pt-SiO<sub>2</sub> and Pd-ZrO<sub>2</sub> GMs [2-4]. These prior GM investigations focused almost exclusively on metal-oxide GMs. Our goal—to develop nanosecond-responsive high-pass filters for electrical grid applications—has advanced development of Mo-SiN<sub>x</sub> GMs that exploit these conductivity mechanisms.

High-dielectric strength SiN<sub>x</sub> is an attractive matrix for GMs, enabling Mo-SiN<sub>x</sub> and Co-SiN<sub>x</sub> GMs [5]. However, initial Mo-SiN<sub>x</sub> GMs showed weak  $\sigma(\omega)$ ; thermally-excited resistive transport through defective SiN<sub>x</sub> overwhelmed the desired transport mechanisms. Fortunately, sputtering Mo-SiN<sub>x</sub> in a partial N<sub>2</sub> environment ameliorates these SiN<sub>x</sub> matrix defects. X-ray photoemission spectroscopy (XPS) analysis shows deleterious MoSi<sub>2</sub> is further reduced by annealing in H<sub>2</sub>/N<sub>2</sub> forming gas (Fig. 1a). Improvements in SiN<sub>x</sub> insulator quality resulted in the desired many decades reduction in  $\sigma_{DC}$  (Fig. 1b). This evaluation of nanostructure and chemical structure has enabled optimization of high-frequency and high electric (*E*) field transport (Fig. 1c, d), key properties of high-pass filters for electric grid applications [6].



**Figure 1**: In (a), the Si 2p XPS spectra for Mo-SiN<sub>x</sub>. In (b),  $\sigma_{DC}$  versus Mo fraction,  $\varphi$ . In (c), frequency response  $\sigma(\omega)$ . In (d), current density, *J*, increases with E-field and  $\varphi$ ; Ohmic, Poole-Frenkel, and Fowler-Nordheim transport are observed.

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